

	L #	Hits	Search Text	DBs
1	L1	3904	(microlens\$6 or micro adj lens\$6 or lenslet or array near2 lens\$4).ti,ab.	US-PGPUB; USPAT
2	L2	48327	(resist or photoresist or photopolymer\$8 or (photosensitiv\$8 or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (polymer or polymeris\$8 or polymeriz\$8 or resin or composition)).ti,ab.	US-PGPUB; USPAT
3	L3	167	1 and 2	US-PGPUB; USPAT
4	L4	272047	(mask or etch\$4 or transfer\$8).ti,ab.	US-PGPUB; USPAT
5	L5	67	3 and 4	US-PGPUB; USPAT
6	L8	774419	second.ti,ab.	US-PGPUB; USPAT
7	L9	248	8 adj3 1	US-PGPUB; USPAT
8	L10	8	2 and 9	US-PGPUB; USPAT
9	L11	759669	through.ti,ab.	US-PGPUB; USPAT
10	L12	25	3 and 11	US-PGPUB; USPAT
11	L13	83	3 not (5 or 12)	US-PGPUB; USPAT
12	L14	1536	430/321.ccls.	US-PGPUB; USPAT
13	L15	95	1 and 14	US-PGPUB; USPAT
14	L16	58	15 not (3 or 10)	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
15	L17	167	216/26.ccls.	US-PGPUB; USPAT
16	L18	21	2 and 17	US-PGPUB; USPAT
17	L19	4	9 and (14 or 17)	US-PGPUB; USPAT
18	L20	27663	(microlens\$6 or micro adj lens\$6 or lenslet or array near2 lens\$4)	US-PGPUB; USPAT
19	L21	480106	(resist or photoresist or photopolymer\$8 or (photosensitiv\$8 or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (polymer or polymeris\$8 or polymeriz\$8 or resin or composition))	US-PGPUB; USPAT
20	L22	3884602	second	US-PGPUB; USPAT
21	L23	2725	22 adj3 20	US-PGPUB; USPAT
22	L24	103	21 same 23	US-PGPUB; USPAT
23	L25	29	okada-kuniaki.in.	US-PGPUB; USPAT
24	L26	4	nagasaka-yukiko.in.	US-PGPUB; USPAT
25	L27	23	kitamura-kazuya.in.	US-PGPUB; USPAT
26	L28	19	sekimoto-yoshihiro.in.	US-PGPUB; USPAT
27	L29	81	kurata-yukio.in.	US-PGPUB; USPAT
28	L30	83	nakanishi-hiroshi.in.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
29	L31	21	(25 or 26 or 27 or 28 or 29 or 30) and 1	US- PGPUB; USPAT
30	L32	17548	(microlens\$6 or micro adj lens\$6 or lenslet or array near2 lens\$4)	EPO; JPO; DERWE NT; IBM_TDB
31	L33	650228	(resist or photoresist or photopolymer\$8 or (photosensitiv\$8 or light or uv or ultraviolet or radiat\$8 or irradiat\$8) near3 (polymer or polymeris\$8 or polymeriz\$8 or resin or composition))	USPAT; EPO; JPO; DERWE NT; IBM_TDB
32	L34	1473384	mask or etch\$4 or transfer\$8	EPO; JPO; DERWE NT; IBM_TDB
33	L35	570	32 and 33 and 34	EPO; JPO; DERWE NT; IBM_TDB
34	L36	2203850	second	EPO; JPO; DERWE NT; IBM_TDB
35	L37	491	36 adj3 32	EPO; JPO; DERWE NT; IBM_TDB
36	L38	13	33 and 37	EPO; JPO; DERWE NT; IBM_TDB

	L #	Hits	Search Text	DBs
37	L39	4323134	through	EPO; JPO; DERWE NT; IBM_TDB
38	L40	2416	32 with 39	EPO; JPO; DERWE NT; IBM_TDB
39	L41	82	35 and 40	EPO; JPO; DERWE NT; IBM_TDB
40	L42	1886945	(beam or expos\$4 or irradiat\$6 or radiat\$6 or uv or ultraviolet)	EPO; JPO; DERWE NT; IBM_TDB
41	L43	2269	32 near5 42	EPO; JPO; DERWE NT; IBM_TDB
42	L44	91	43 and 35	EPO; JPO; DERWE NT; IBM_TDB
43	L45	63	44 not (38 or 41)	EPO; JPO; DERWE NT; IBM_TDB

	L #	Hits	Search Text	DBs
44	L46	167251	three adj dimension\$8 or 3d	EPO; JPO; DERWE NT; IBM_TDB
45	L47	32	35 and 46	EPO; JPO; DERWE NT; IBM_TDB
46	L48	512469	condens\$8 or focus\$8	EPO; JPO; DERWE NT; IBM_TDB
47	L49	44	33 and 34 and 46 and 48	EPO; JPO; DERWE NT; IBM_TDB
48	L50	39	49 not (38 or 41 or 44 or 47)	EPO; JPO; DERWE NT; IBM_TDB
49	L53	2000	359/619,620,622,642.ccls.	US- PGPUB; USPAT
50	L54	70	2 and 53	US- PGPUB; USPAT
51	L56	35	54 not (3 or 10 or 15 or 18)	US- PGPUB; USPAT
52	L57	29457	(three adj dimensional or 3d).ti,ab.	US- PGPUB; USPAT
53	L58	85841	(condens\$8 or focus\$8).ti,ab.	US- PGPUB; USPAT

	L #	Hits	Search Text	DBs
54	L59	11	2 and 4 and 57 and 58	US-PGPUB; USPAT
55	L60	899853	(condens\$8 or focus\$8)	US-PGPUB; USPAT
56	L61	358736	(three adj dimensional or 3d)	US-PGPUB; USPAT
57	L62	446	21 same 60 same 61	US-PGPUB; USPAT
58	L63	1912751	(mask or etch\$4 or transfer\$8)	US-PGPUB; USPAT
59	L64	147	62 same 63	US-PGPUB; USPAT
60	L65	43	(1 or 58) and 64	US-PGPUB; USPAT
61	L66	32	65 not 59	US-PGPUB; USPAT